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# **Thermoplastic Resists for Nanoimprint Lithography**

#### mr-I 7000R and mr-I 8000R – Thermoplastics with Built-in Release Properties

• Tailor-made for thermal nanoimprint lithography



75 nm and 100 nm lines imprinted in mr-I 8030R, varying pitch



12 nm trenches, 50 nm pitch, imprinted in mr-I 7000R (Courtesy of Eulitha AG and Paul Scherrer Institute)

# Easy stamp detachment, efficient release force reduction

Longer life-time of anti-sticking layer on the mould

### **Unique Features**

- Excellent properties for thermal NIL
  - Short cycle times due to fast polymer flow
  - Sub-20 nm resolution
  - Low residual layer thickness
- Low release forces
- <sup>-</sup> Longer life-time of anti-sticking layers on the stamp
- <sup>–</sup> High plasma etch resistance

# **Technical Data**<sup>1</sup>

# Applications

- <sup>–</sup> Etch mask for pattern transfer
- <sup>–</sup> Fabrication of nanopatterns for
  - <sup>-</sup> High brightness LEDs
  - <sup>–</sup> Photonic crystals
  - <sup>-</sup> Patterned media
  - Nano-optical devices, sub-
- wavelength optical elements
- Microfluidics, bio applications



50 nm lines imprinted in mr-I 7030R (Courtesy of Paul Scherrer Institute)

receptor
200000000

Parameter	mr-I 7000R	mr-I 8000R
Glass transition temperature T <sub>a</sub>	50 °C	105 °C
Imprint temperature	120 – 140 °C	150 – 180 °C
Imprint pressure	20 – 40 bar	20 – 40 bar
Ready-to-use solutions for standard film thicknesses <sup>2</sup> (3000 rpm)	mr-17010R 100 nm	mr-18010R 100 nm
	mr-1 7020R 200 nm	mr-18020R 200 nm
	mr-1 7030R 300 nm	mr-18030R 300 nm

<sup>1</sup> Processing guidelines available on request

<sup>2</sup> Customized film thicknesses available on request

#### **Release Force Reduction**



#### **Process Flow**





75 nm and 100 nm squares imprinted in mr-I 7030R



mrt logo imprinted in mr-I 7030R





Forces during stamp release: comparison between mr-I 7000R to its non-modified analogue mr-I 7000E



#### Conventional resist formulations mr-I 7000E and mr-I 8000E

without fluorinated components are still available upon request in equal film thickness ranges.